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Filter Synthesis
Techniques**

Chair: Richard Snyder¹
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**EuMC20-1
Quasi-MMIC High Power
Amplifier with Silicon IPD
Matching Network**

Junhyung Jeong¹, Phirun Kim¹, Phanam Pech¹,
Jongsik Ilm², Yongchae Jeong²
¹Chonbuk National University, ²Soonchunhyang
University

**EuMC21-1
Lossy Dual-Mode
Bandpass Filter With
Non-Uniform Q Method**

Hongliang Guo¹, Jia Ni¹, Jiasheng Hong¹, Petronilo
Martin Iglesias²
¹Heriot-Watt University, ²European Space Agency,
ESA/ESTEC

**EuMC22-1
Miniaturization Design of
Millimeter Wave
Conformal Array Antenna**

Jingping Liu¹
¹Nanjing University of Science and Technology

**EuMC23-1
300-GHz CMOS Receiver
Module with WR-3.4
Waveguide Interface**

Shinsuke Hara¹, Kyoya Takano², Kosuke Katayama²,
Ruibing Dong², Koichi Mizuno², Kazuaki Takahashi²,
Issei Watanabe¹, Norihiko Sekine¹, Akifumi
Kasamatsu¹, Takeshi Yoshida², Shuhei Amakawa²,
Minoru Fujishima²
¹National Institute of Information and
Communications Technology, ²Hiroshima University,
³Panasonic Corporation

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**EuMC20-2
New Class-F High
Efficiency Multi-Bias
Optimised GaN HPA for
C-Band Applications**

Wilfried Dementroux¹, Lucas Mandica¹, Nicolas
Berthou¹, Frederic Ploneis¹, Audrey Thorinius²
¹Thales Communications & Security, ²Thales DMS

**EuMC21-2
Linear Time-Invariant
Behavioral Digital Models
of Frequency-Periodic RF/
Microwave Filters**

Jose-Mania Munoz-Ferreras¹, Dimitra Psychogiou²,
Roberto Gomez-Garcia¹
¹University of Alcalá, ²University of Colorado at
Boulder

**EuMC22-2
Novel Single/Dual Beam
Scanning Provided by an
Array Composed of Two
CRLH SIW LWAs**

Rihem Noumi¹, Jan Machac², Ali Ghareisallah¹
¹Faculty of Sciences of Tunisia, ²Czech Technical
University in Prague

**EuMC23-2
Monopulse RLSA Antenna
with Gap-Waveguide
Feeding Network for
Space Debris Radar at 94
GHz**

Adrián Tamayo Domínguez¹, José Manuel
Fernández-González¹, Manuel Sierra Castañer¹
¹Universidad Politécnica de Madrid

08:50 - 09:10

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Wideband High Efficiency
50 W GaN-HEMT Balanced
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Quang Huy Le¹, Gemot Zimmer^{1,2}
¹Frankfurt University of Applied Sciences,
²Vietnamese-German University

**EuMC21-3
A Theoretical Synthesis of
Coupling Matrix by Eigen
Mode Expansion Method
and Householder
Transform**

Shigeki Takeda¹, Tetsuo Anada², Chun-Ping Chen²
¹Antenna Giken Co., Ltd., ²Kanagawa University

**EuMC22-3
Perforated Rectangular
Dielectric Resonator
Antenna for Wideband,
Dual band and Single
band application**

Pragati Patel¹, Eeshaan Vernekar¹, Mallikarjun
Erramshetty¹
¹NIT Goa

**EuMC23-3
E-band Radio Fiber as
Low-Cost mm-Wave
Waveguide Junction**

Stefano Moscato¹, Matteo Oldoni¹, Giuseppe Parisi²
¹StAE Microelettronica, ²SM-Optics

09:10 - 09:30

**EuMC20-4
50% High Efficiency
X-Band GaN MMIC
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Applications**

Anne-Marie Couturier¹, Nicolas POITRENAUD¹,
Véronique SERRU¹, Jean-Jacques FONTECAVE¹,
Roberto DIONISIO², Marc Camiade¹
¹United Monolithic Semiconductors SAS, ²ESA

**EuMC21-4
Application of a Series
Open Circuit Stub
Transform to Bandpass
Filter Design.**

Johannes Malherbe¹
¹University of Pretoria

**EuMC22-4
An Electrical-Contactless
Substrate-Over-
Waveguide Planar Array
Slot Antenna**

Alfonso Tomás Muriel-Barrado¹, Manuel Sierra
Perez¹, José Manuel Fernández-González¹
¹Technical University of Madrid

**EuMC23-4
Terahertz Gapless Low
Insert Loss Waveguide
Switch Technology**

Chuxian Zhang¹
¹Beijing Aerospace Research Institute of Micro
Electrical-Mechanical Technology

09:30 - 09:50

**EuMC21-5
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Filters Using Single-Short-
Circuited-Stub-Loaded
Parallel-Coupled-Lines**

Chun-Ping Chen¹, Daisuke Tetsuda¹, Zejun Zhang¹,
Tetsuo Anada¹, Shigeki Takeda², Zhenwang Ma²,
Xiaolong Wang²
¹Kangawa University, ²Antenna Giken Co., Ltd.,
³Gaitama University

**EuMC22-5
Compact Cavity-Backed
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Enhanced Axial Ratio and
Gain at Low Frequencies**

Andrea García-Estellés¹, Juan José Sánchez-
Martínez¹, Ana Cristina Gago-Lancho¹, Francisco
Vázquez-Vázquez¹
¹Indra Sistemas S.A.

**EuMC23-5
THz and Microwave
Dual-Band Ultrafast
Photoconductive Antenna**

Elliott Brown¹, Andrea Mingardi¹, Weidong Zhang¹,
Enrique Garcia², Guillermo Carpintero², Daniel
Segovia-Vargas²
¹Wright State University, ²University Carlos III Madrid

09:50 - 10:10

Quasi-MMIC High Power Amplifier with Silicon IPD Matching Network

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Abstract — In this paper, the quasi-monolithic microwave integrated circuit (MMIC) high power amplifier (HPA) with silicon integrated passive device (IPD) matching network is proposed. The proposed quasi-MMIC HPA consists of commercial GaN transistor power cell and IPD matching network using silicon substrate. The proposed quasi-MMIC HPA can achieve similar output power and efficiency characteristics compared with the conventional MMIC HPAs. Moreover, the manufacturing cost can be reduced due to the silicon substrate process. For experimental validation, the proposed quasi-MMIC HPA was designed and fabricated at the 8.5 GHz for radar application. The measurement results shows that the output power and drain efficiency at saturation point are 48.5 dBm (70.8W) and 45.5%, respectively, with pulse signal test (100 usec pulse width and 10% duty).

Keywords — high resistivity silicon, integrated passive device matching network, internally matched, power amplifier, quasi-MMIC, radar.

I. INTRODUCTION

Power amplifier (PA) is an important circuit in RF wireless communication and radar systems. Especially, high power performance of PA is required in military radar systems to increase the detection range. To achieve power requirement, PAs are used in the radar system as shown in Fig.1 because of limited output power capability of transistor. The number of PA/LNA is decided according to number of array antennas and the individual transmitting powers are combined and radiated in array antenna. Also, size and product cost of individual PA are important issues because overall size and cost according to number of array of PAs are increased. Therefore, PA block in radar system should be considered high output power, efficiency, size, and cost simultaneously.

Conventional GaAs monolithic microwave integrated circuit (MMIC) is one of several solutions with high integration level, broadband output, and efficiency performances. Moreover, the design freedom is high because the lumped elements such as resistor, capacitor, and inductor can be easily modeled and used. Nevertheless, power capability of GaAs MMIC is not enough for the radar system. Therefore, GaN-on-SiC MMIC technologies were developed to increase output power in MMIC process [1]-[2]. They consisted of transistor power cell realized with the GaN material and the passive matching network (MN) with MMIC technology on SiC substrate. As using GaN transistor and SiC substrate, high output power and efficiency can be obtained at microwave frequency. And good heat dissipation characteristics are also obtained. However, manufacturing cost

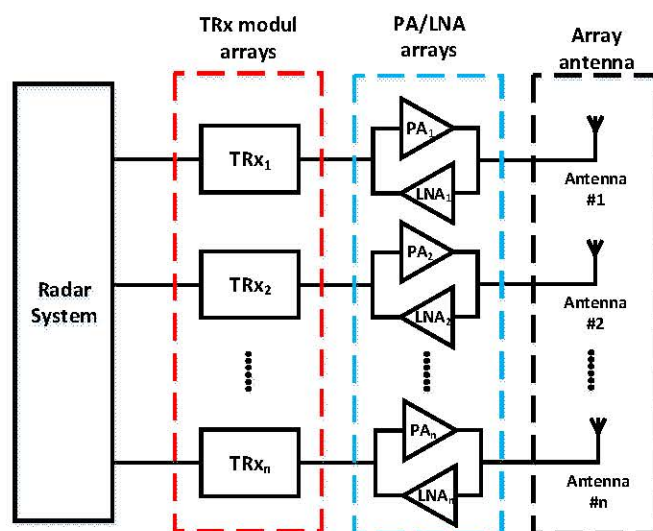


Fig. 1. Block diagram of radar system

and difficulty of process are increased due to the GaN process on SiC substrate.

Another approach is quasi-MMIC structures. The quasi-MMIC structures consisted of the passive MNs realized with high dielectric substrate printed circuit board (PCB) or GaAs MMIC process and the commercial GaN transistor power cell [3]-[6]. Each input/output passive MNs are connected with GaN transistor by bonding wire. However, the manufacturing cost is increased according to the compositions of PCB, the specific material of substrate, and GaAs MMIC process. In case of high dielectric PCB MNs, the design freedom is reduced than conventional MMIC MNs because the lumped elements cannot be implemented in the MN. Moreover, the precise implementation process is required to avoid input/output matching characteristics variation due to the fabrication errors of transmission line and bonding wire.

In this paper, the quasi-MMIC high power amplifier (HPA) with silicon (Si) integrated passive device (IPD) MN is presented. Compared with the conventional quasi-MMIC HPAs, the proposed HPA provides lower manufacturing cost due to the Si substrate. Moreover, the proposed HPA has high integration level passive circuits and the design freedom because the conventional standard Si IPD process techniques can be used. For a validation, the design procedure and experimental results of the quasi-MMIC HPA with Si IPD MN are provided.

II. A DESIGN OF PROPOSED QUASI-MMIC HPA

This section provides a rough description of the Si IPD process for realizing a passive networks and the actual HPA design procedures. Because the passive circuit of proposed quasi-MMIC HPA can utilize the conventional Si semiconductor process technology, not only thin film $R-L-C$ devices but also silicon through via (TSV) can be used.

Fig. 2 shows the implementation example of grounded series $R-L-C$ circuit with high resistivity silicon (HRS) substrate. At first the TSV is implemented on the HRS substrate for the ground, and then the resistor is implemented using NiCr and attached on Metal 1 for the connection with signal line. Secondly, SiNx is used to fabricate a dielectric layer for metal-insulator-metal capacitors, and Metal 2 is used to fabricate capacitors and spiral inductors. Then, WPR covers SiNx and Metal 2 areas except some part to connect with Metal 3. Thirdly, the pad for the bonding wire and the signal line to connect the spiral inductor at Metal 2 are realized by top Metal 3. Finally, the WPR passivation is done whole circuit except the pad for the bonding wire. Using this process, input and output MNs can be minimized and implemented using lumped elements and transmission lines on a HRS substrate

The proposed quasi-MMIC HPA was designed using a 70 W pulse mode GaN HEMT transistor (CGHV1J070D) of Wolfspeed at 8.5 GHz (f_0). The selected bias condition was $V_{DD} = 48$ V, $V_{GS} = -2.6$ V, and $I_{DQ} = 330$ mA. As load-pull simulation, the optimum load impedance (Z_{opt}) is $1.46 + j2.2 \Omega$ with saturation output power of 49 dBm. The input matching impedances of transistor at f_0 and $2f_0$ are chosen 2Ω and $1 + j10 \Omega$ by source-pull simulation.

The used GaN TR has twelve pads at the gate and drain ends, respectively. Therefore, the feeding circuit for connecting each pad to the matching circuit affects circuit characteristics. Fig. 3 shows the signal line circuit (SLC) and taper bus structure networks and the transfer characteristics from each pad to the output. Whereas the SLC structure shows relatively uniform transfer characteristics than the taper bus structure, the taper structure shows several different transfer characteristics according to pad locations. Especially, there is serious difference between the paths through the pads at both ends to the output and the paths through the center pads to the output. Because the signals of individual pads in the SLC structure are sequentially combined, the output powers at all pads are well combined at the final output stage, so that high output power and efficiency are achieved

Fig. 4 show the EM simulation result of the output MN using SLC structure and bonding wire. The load impedance at f_0 is $1.36 + j2.3 \Omega$ for the Z_{opt} point. Even though the harmonic matching circuit is not implemented to reduce the insertion loss of the MN, it shows that the second harmonic ($2f_0$) impedance is matched at the short circuit point due to the shunt parasitic capacitance of the MN with Si substrate. The input MN is also implemented using the same structure.

Fig. 5 shows the measured gain and drain efficiency (DE) of the proposed HPA according to the output power. The measurement results show that the output power and DE are 48.5 dBm, and 45.5%, respectively, at the saturation point with pulse signal (width = 100 usec and duty = 10%). Fig. 6 shows the output power and DE according to the operating frequency. Bandwidth of output power over 60 W is 330 MHz, where DE

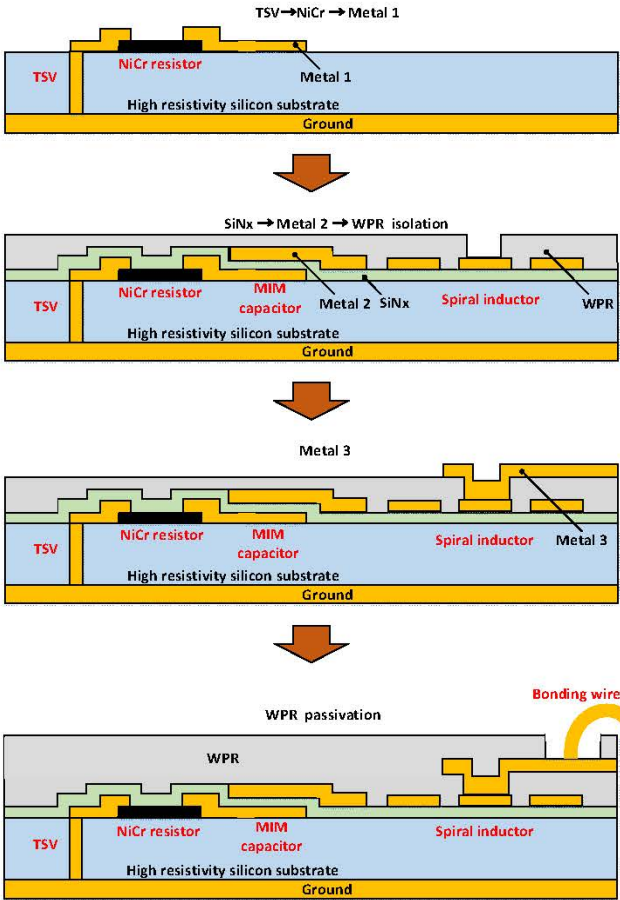


Fig. 2. Passive network fabrication procedure

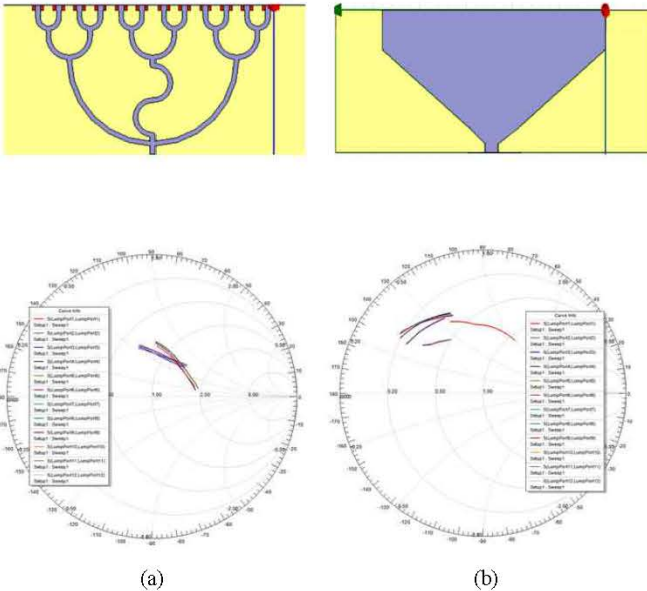


Fig. 3. Signal transfer characteristics of feeding networks at each transistor pad: (a) signal line circuit and (b) taper bus structure.

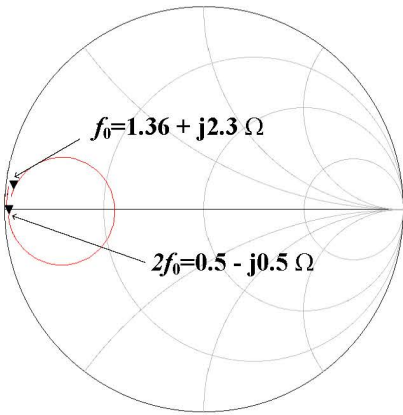


Fig. 4. EM simulation result of designed output matching network.

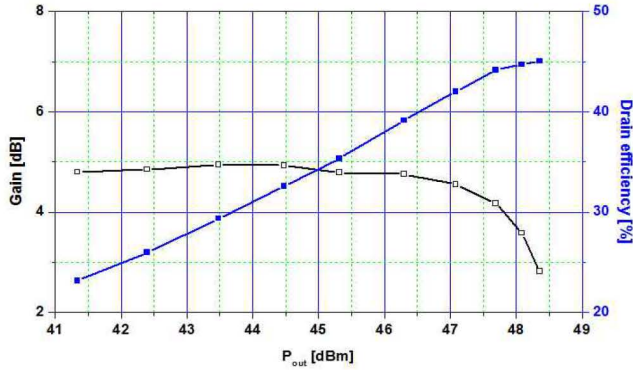


Fig. 5. Measured gain and drain efficiency of quasi-MMIC HPA with Si IPD MN at 8.5 GHz.

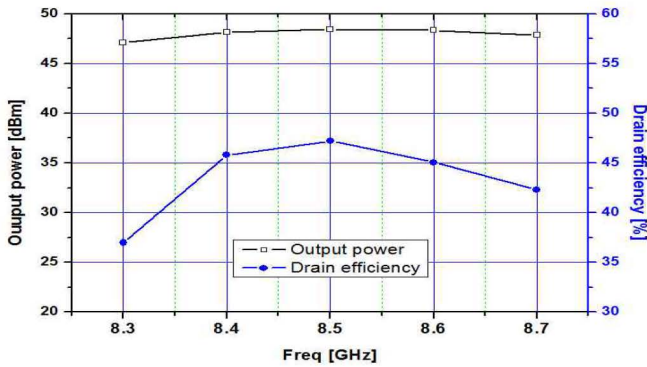


Fig. 6. Frequency characteristics of quasi-MMIC HPA with Si IPD MN.

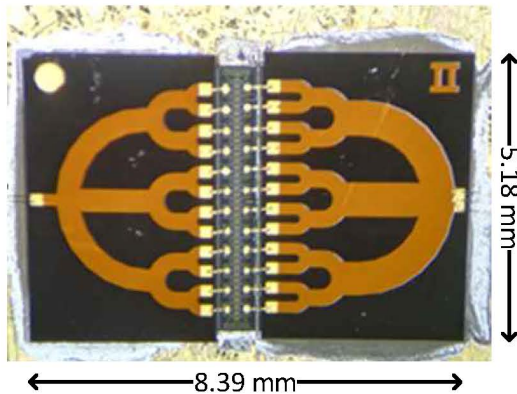


Fig. 7. Photograph of fabricate quasi-MMIC HPA with silicon IPD MN

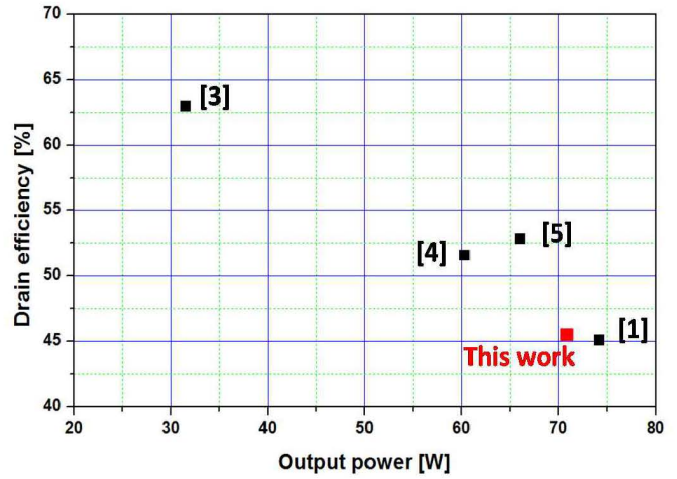


Fig. 8. State-of-art of the drain efficiency versus output power between X-band HPAs

is more than 40%. Fig. 7 is a photograph of quasi-MMIC HPA with Si IPD MN. GaN transistors were eutectic bonded using Au and Si IPD was fixed using silver epoxy. The MN and GaN TR were connected using a 2 mil gold wire whereas the input and output ports were connected to an external circuit using a 1 mil gold wire. The input and output feeds were designed with 100 μm and 200 μm , respectively, to endure supply DC current and high output RF power.

Fig. 6 shows the output power and DE according to the operating frequency. Bandwidth of output power over 60 W is 330 MHz, where DE is more than 40%. Fig. 7 is a photograph of quasi-MMIC HPA with Si IPD MN. GaN transistors were eutectic bonded using Au and Si IPD was fixed using silver epoxy. The MN and GaN TR were connected using a 2 mil gold wire whereas the input and output ports were connected to an external circuit using a 1 mil gold wire. The input and output feeds were designed with 100 μm and 200 μm , respectively, to endure supply DC current and high output RF power.

III. COMPARISON WITH CONVENTIONAL HPAs

In this section, the state-of-art is presented to show that the proposed circuit is suitable for comparison with other X-band HPAs. Table 1 shows the characteristics of the conventional HPA and the proposed quasi-MMIC HPA in the X-band. The proposed circuit has similar or better characteristics compared to the MMIC HPA using SiC substrate. Compared with researches used quasi-MMIC structure, the efficiency is slightly lower but the output power is higher. In the view of size between same structures, the proposed HPA is small relative to the output power. Fig. 8 shows state-of-art with DE efficiency versus output power. It can be seen that the proposed circuit is located together with conventional studies at the lower right side. Therefore, the proposed quasi-MMIC HPA has similar characteristics to those of the conventional studies and has a great advantage in terms of manufacturing cost.

Table 1. Performance comparison with previous works.

Ref.	Freq. [GHz]	Output power [W]	Drain efficiency [%]	Fabrication process	Pulse signal width [usec] / duty [%]	Size [mm ²]
[1]	9.2	74.13	45.1*	MMIC (SiC Substrate)	100 / 10	3.5×3.8
[2]	10	13.4	25.7*	MMIC (SiC Substrate)	100 / 10	4.5×3
[3]	10	31.5	63*	Quasi-MMIC (3 kinds PCBs: $\epsilon_r=10, 90$ and 38)	Non / 10	5.4×3.8
[4]	X-band	60.3	51.57*	Quasi-MMIC (2 kinds PCBs: $\epsilon_r=38$ and 10)	80 / 10	7×7.7
[5]	9.4	66	52.8*	Quasi-MMIC ($\epsilon_r=36$)	100 / 10	9.6×8.6
This work	8.5	70.8	45.5	Quasi-MMIC (Si IPD)	100 / 10	8.39×5.18

* calculated value.

IV. CONCLUSION

In this paper, the quasi-MMIC HPA with silicon (Si) integrated passive device (IPD) matching network (MN) is described. Proposed HPA is used quasi-MMIC structure with standard Si IPD MNs at input/output both sides. For the uniform power transmitting of each pad and effective combination at the output, the signal line circuit feeding structure was used. The fabricated quasi-MMIC HPA with Si IPD MN has high output power and efficiency similar to those of the conventional researches. Therefore, the proposed quasi-MMIC HPA can reduce the manufacturing cost with high output power and efficiency performances and it can be apply to the array radar systems.

ACKNOWLEDGMENT

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